

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

1 - 8. (canceled).

9. (previously presented): A circuit board comprising a substrate and built thereon, a circuit comprised of a copper film,

wherein said copper film comprises an electroplated layer and has properties that (a) its crystallinity is such that the X-ray diffraction half-width of the (331) plane of copper is less than 0.3 deg. and (b) the variation in thickness ((maximum thickness-minimum thickness)/average thickness) of said copper film as measured over the whole surface of said substrate is not greater than 0.4.

10. (original): The circuit board according to Claim 9 wherein said copper film has an elongation of not less than 7%.

11. (previously presented): A printed circuit board comprising a substrate and, built thereon, a circuit comprised of a copper film,

wherein said copper film comprises an electroplated layer and has properties that (a) its crystallinity is such that the X-ray diffraction half-width of the (331) plane of copper is less than 0.3 deg. and (b) the variation in thickness ((maximum thickness-minimum thickness)/average thickness) of said copper film as measured over the whole surface of said substrate is not greater than 0.4.

12. (previously presented): A printed circuit board comprising a substrate formed with a conductor circuit, an interlayer resin insulating layer thereon and a conductor circuit comprised of a copper film on said interlayer resin insulating layer and having via holes by which said conductor circuits are interconnected,

wherein said copper film comprises an electroplated layer and has properties that (a) its crystallinity is such that the X-ray diffraction half-width of the (331) plane of copper is less than 0.3 deg. and (b) the variation in thickness ((maximum thickness-minimum thickness)/average thickness) of said copper film as measured over the whole surface of said substrate is not greater than 0.4.

13. (previously presented): The printed circuit board according to Claim 11 wherein said copper film has an elongation of not less than 7%.

14 - 22. (canceled).

23. (previously presented): A printed circuit board comprising a resin insulating substrate board formed with a roughened surface and, built thereon by semi-additive process, a conductor circuit comprising an electroless plated film and an electroplated film,

wherein said roughened surface comprises convex areas and concave areas, and said electroless plated film is complementary to a surface of said roughened surface with said electroless plated film in convex areas of said roughened surface being relatively greater in thickness than said electroless plated film in concave areas of said roughened surface.

24. (currently amended): A printed circuit board comprising a substrate board formed with a lower-layer conductor circuit and, built thereon by a build-up process, an upper-layer

conductor circuit with an interlayer resin insulating layer interposed in between, said upper-layer conductor circuit and said lower-layer conductor circuit being interconnected by via holes,

wherein said lower-layer conductor circuit has a roughened surface on a side which contacts with said interlayer resin insulating layer, said upper-layer conductor circuit comprises an electroless plated film and an electroplated film, said interlayer resin insulating layer is provided with a roughened surface, with said electroless plated film being complementary to said roughened surface,

said interlayer resin insulating layer and said via holes are provided with the same electroless plated film, with said electroless plated film formed on the bottoms of said via holes having a thickness equal to 50 to 100% of the thickness of said electroless plated film on said interlayer resin insulating layer, and

said lower-layer conductor circuit and said electroless plated film formed on the bottom of said via hole are connected through said roughened surface of said lower-layer conductor circuit, and

said via hole has a diameter of 80 μm or less.

25. (previously presented): The printed circuit board according to Claim 23,

wherein said electroless plated film is a copper film which contains at least one metal species selected from the group consisting of nickel, iron and cobalt.

26. (original): The printed circuit board according to Claim 25 wherein the proportion of said at least one metal species selected from the group consisting of nickel, iron and cobalt is 0.1 to 0.5 weight %.

27 - 31. (canceled).

32. (currently amended): A multilayer printed circuit board comprising a core board having on both sides conductor circuits and, over each of said conductor circuits, buildup wiring layers comprising alternating an interlayer resin insulating layer and a conductor layer thereon, wherein the conductor layers having a thickness of 10 to 30 μm are interconnected by via holes,

wherein said core board comprises a plated-through hole and a copper-clad laminate, each of said conductor circuit comprises a copper foil of said copper-clad laminate and a plated metal layer,

said conductor circuit on said core board is a conductor layer interconnected with said plated-through hole, and

the thickness of each of said conductor circuit is not greater by more than 10 μm than the thickness of said conductor layer on said interlayer resin insulating layer.

33 - 36. (canceled).

37. (currently amended): A multilayer printed circuit board comprising a core board having on both sides conductor circuits and, over each of said conductor circuits, a buildup wiring layer comprising alternating an interlayer resin insulating layer and a conductor layer thereon, wherein said conductor layers are interconnected by via holes,

wherein said core board is a copper-clad laminate, and is provided with plated-through holes, each of said plated-through holes has a through hole piercing through said core board, having been plated and filled with a filler,

said conductor circuits comprise a copper foil of said copper-clad laminate and a plated film, and

said via holes are formed immediately over said plated-through holes so as to cover the whole opening of the through holes in said plated-through holes and are interconnected with said plated-through holes.

38. (original): The multilayer printed circuit board according to Claim 37 wherein the through holes in said plated-through holes have a diameter of not more than 200 μm .

39. (canceled).

40. (currently amended): The multilayer printed circuit board according to claim 37, wherein

said filler comprises a metal particle, and

lower-layer via holes are disposed immediately over said plated-through holes, said plated-through holes being interconnected with said lower-layer via holes, ~~and upper-layer via holes are disposed immediately over said lower-layer via holes, said upper-layer via holes being interconnected with said lower-layer via holes.~~

41. (currently amended): A multilayer printed circuit board comprising a core board and, on both sides thereof, buildup wiring layers comprising alternating an interlayer resin insulating layer and a conductor layer thereon, wherein the conductor layers are interconnected by via holes,

wherein said core board is provided with plated-through holes, each of said plated-through holes has a through hole piercing through said core board, having been plated and filled with a filler,

with the whole surfaces of said filler which are exposed from said plated-through holes being covered with said conductor layer provided with lower-layer via holes, ~~and upper-layer via holes are disposed immediately over said lower-layer via holes, said lower-layer via holes being interconnected with said upper-layer via holes.~~

42. (currently amended): A multilayer printed circuit board comprising a core board and, on both sides thereof, buildup wiring layers comprising alternating an interlayer resin insulating layer and a conductor layer thereon, wherein the conductor layers are interconnected by via holes,

wherein said core board is provided with plated-through holes, and lower-layer via holes are disposed to cover the whole opening of through holes of said plated-through holes, said plated-through holes being interconnected with said lower-layer via holes, ~~and upper-layer via holes are disposed immediately over said lower-layer via holes, said upper-layer via holes being interconnected with said lower-layer via holes.~~

43. (original): The multilayer printed circuit board according to any of Claims 40 to 42 which comprises bumps formed immediately above said plated-through holes.

44. (previously presented): The multilayer printed circuit board according to any of Claims 40 to 42, wherein said lower-layer via holes are filled with metal.

45. (original): The multilayer printed circuit board according to any of Claims 40 to 42 wherein valleys of said lower-layer via holes are filled with a conductive paste.

46. (original): The multilayer printed circuit board according to any of Claims 40 to 42 wherein valleys of said lower-layer via holes are filled with a resin.

47. (canceled).

48. (previously presented): The circuit board according to Claim 9, wherein said copper film is formed by constant-voltage pulse plating technique.

49. (previously presented): The printed circuit board according to Claim 11, wherein said copper film is formed by constant-voltage pulse plating technique.

50. (previously presented): The printed circuit board according to Claim 12, wherein said copper film has an elongation of not less than 7%.

51. (previously presented): The printed circuit board according to Claim 12, wherein said copper film is formed by constant-voltage pulse plating technique.

52. (previously presented): The printed circuit board according to Claim 23, wherein said electroless plated film is formed from an electroless plating solution comprising tartaric acid or a salt thereof.

53. (previously presented): The printed circuit board according to Claim 23, wherein said roughened surface comprises a primary anchor and a secondary anchor, said primary anchor having concave and convex parts and said secondary anchor being formed on the convex areas of said roughened surface.

54. (previously presented): The printed circuit board according to Claim 24, wherein said electroless plated film is formed from an electroless plating solution comprising tartaric acid or a salt thereof.

55. (canceled).

56. (previously presented): The printed circuit board according to Claim 25, wherein said electroless plated film comprises an alloy of copper and at least one metal species selected from the group consisting of nickel, iron and cobalt.

57. (canceled).

58. (previously presented): The multilayer printed circuit board according to claim 37, wherein said filler comprises SiO₂ beads having a maximum particle size of 15 μm.

59. (previously presented): The multilayer printed circuit board according to claim 37, wherein each of said conductor circuits on said core board has a roughened layer on its surface.

60. (previously presented): The multilayer printed circuit board according to claim 41, wherein said filler comprises SiO₂ beads having a maximum particle size of 15 μm.

61. (previously presented): The multilayer printed circuit board according to claim 41, wherein each of said conductor circuits on said core board has a roughened layer on its surface.

62. (currently amended): A multilayer printed circuit board comprising a core board and, on both sides thereof, buildup wiring layers comprising alternating an interlayer resin

insulating layer and a conductor layer thereon, wherein the conductor layers are interconnected by via holes,

wherein said core board is provided with plated-through holes,
each of said plated-through holes has a through hole piercing through said core board, having been plated and filled with a filler, with the whole surfaces of said filler which are exposed from said plated-through holes being covered with the conductor layers provided with lower-layer via holes, and said lower-layer via holes being interconnected with said plated-through holes via the conductor layer.

63. (previously presented): The printed circuit board according to claim 23, wherein said electroless plated film has a stress of 0 to +10 kg/mm².

64. (new): The multilayer printed circuit board according to claim 40
wherein
said metal particle is at least one selected from the group consisting of copper, gold, silver, aluminum, palladium and platinum.

65. (new): The multilayer printed circuit board according to claim 40
wherein
particle diameter of said metal particle is within the range of 0.1 to 50 μm .

66. (new): The multilayer printed circuit board according to any of claims 40 to 42
wherein
upper-layer via holes are disposed immediately over said lower-layer via holes and interconnected with said lower-layer via holes.

67. (new): The multilayer printed circuit board according to any of claims 40 to 42

wherein

a plated film constituting said lower-layer via hole is connected with a plated film
constituting said plated-through hole.